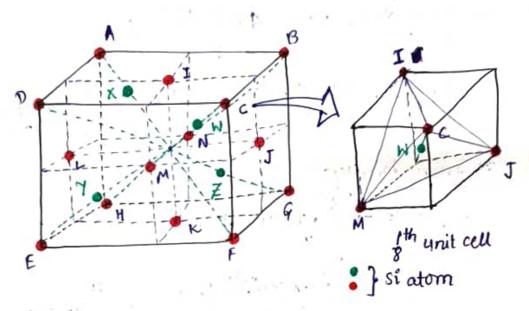
1

1 Draw the crystal Structure of Silicon and GaAs.

Sons Si has diamond structure in which the silicon atoms form Fcc as well as the alternate tetrahedual voids.



GaAs has zinc Hend crystal structure similar to diamond Structure in which As form forms FCC and Ga takes alternate tetrahedral voids

2 Calculate the number of atoms present in 1cm3 of silicon.

Sqn: Density of or material = 2.33 g/cm3,

> Weight of Lcm3 Si = 2.33 g

⇒ Moles of Si = 2.33 28.08

[ Molar mass of Si= 28.08 g/mol.]

= 0.083

⇒ No. of Si atoms = 0.083 × 6.0 23 × 10<sup>23</sup> (Avogaduo's no, NA=6.023) ≈ 5×10<sup>22</sup>

There are ~5×1022 si atoms in 1 cm3 of si.

3 Using the density of states and the Fermi probability function, derive the expression for the convier density of holes in the volence band and electrons in the conduction band in terms of fermi integrals. Invoking Boltzmann approximation, recalculate the holes and electron densities. Assume that the semiconductor is moderately doped.

John: Density of state,  $g(E) = \frac{4\pi (2m!)^{3/2}}{\hbar^3} \sqrt{E}$ 

fermi probability function,  $f(E) = \frac{1}{1 + e^{\frac{E-E_1}{k_1}}}$ 

Electron density:

no= in (E) dE= ig(E), I(E) dE

EC EC

$$= \int_{E_c}^{E_{\infty}} 4\pi (2m_e)^{3/2} \sqrt{E-E_c} \cdot \frac{dE}{1+e(E-E_f)}$$
Ec

Let  $\frac{E-E_C}{KT} = u$ , and  $\frac{E_W}{KT} = \frac{E_F-E_C}{KT} = u_f$  $\Rightarrow dE = KT du$ 

 $= 4\pi \left(\frac{2KTm_e^*}{h^2}\right)^{3/2} \int \frac{u^{1/2} du}{1+(u-u_f)^{3/2}}$ 

$$\Rightarrow n_o = N_c \int \frac{u^2 du}{1 + e^{(u-u_f)}}, \text{ where } N_c = 4\pi \frac{2 kT}{h^2} \text{ me} \frac{1^3 2}{h^2}$$
is the effective density

is the effective density of states of CB.

$$\int_{(E)} \frac{1}{1 + e^{(E-Ef)NKT}} \approx \frac{1}{e^{(E-Ef)NKT}} \approx \frac{1}{e^{(E-Ef)NKT}} \approx e^{-(E-Ef)NKT}$$

$$\therefore \eta_0 = \int_{(E)} g(E) f(E) dE$$

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$$=\frac{4\pi}{h^3}\frac{(2me^*)^{3/2}(kT)^{3/2}e^{-\left(\frac{E_c-E_f}{kT}\right)\sqrt{\Lambda}}}{h^3}$$

$$\Rightarrow \left(n_0 = 2\left(\frac{2\pi m_e^* \kappa T}{h^2}\right)^{3/2} e^{-\frac{(E_c - E_f)}{kT}}\right)$$

Proble density:

$$P_{0} = \int_{\text{PLE}}^{\text{EV}} dE = \int_{-\infty}^{\text{EV}} (1 - f(E)) g_{VB} dE$$

$$= \int_{-\infty}^{\text{EV}} e^{\left(\frac{E-E_{f}}{KT}\right)} \frac{4\pi \left(2m_{K}^{*}\right)^{3/2}}{h^{3}} \sqrt{E_{V}-E} dE$$

$$= K'' \int_{-\infty}^{\text{EV}} e^{\left(\frac{E-E_{f}}{KT} + E_{V}-E_{V}\right)} \int_{\text{EV}}^{\text{EV}-E} dE, \text{ where}$$

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$$= K'' = 4\pi \left(\frac{2m_{K}^{*}}{KT}\right)^{3/2}$$

= 
$$4\pi \left(\frac{2\kappa T m_{k}^{*}}{h^{2}}\right)^{3/2} \int \left(1 - \frac{1}{e^{(4\gamma' - u')}}\right) u'^{1/2} du'$$

FOU E>> & OH (E-Ef)>>KT,

$$= K'' \left[ (1 - f(E)) g_{VB}(E) dE \right]$$

$$= K'' \left[ (1 - e^{-(E - Ef + Ev - Ev})) \right]$$

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$$= K'' \int \left(1 - e^{-KT}\right)^{KT}$$

$$\Rightarrow \left[ s_0 = 2 \frac{2\pi m_h^* k \Gamma}{h^2} \right]^{3/2} e^{-\frac{E_f - E_V}{KT}}$$

For an n-type Si sample, the Fermi energy is assumed to be 0.3 eV below the Enduction band edge. Calculate the electron and hale concentrations in the comple at 300K. For Silicon, assume that the Bandgap is 1.1 eV, ni=15×1010 cm-3. You can assume that the intrinsic Fermi level is at the mid-bandgap. Recalculate the values by using the exact yelation for the position of intrinsic fermi level, and compare the results. [Use me = 0.98 mo, mh = 0.49 mo.]

= 
$$1.5 \times 10^{10} \times 22,026.47$$
  
=  $3.3 \times 10^{14} / cm^3$ .

and, 
$$p_0 = \frac{n_1^2}{n_0} = \frac{(15 \times 10^{10})^2}{3.3 \times 10^{14}} = 6.8 \times 10^5 / \text{cm}^3$$

Exact value of Efi:

$$\Rightarrow \text{Efi-EV} = \frac{3}{4} (25 \text{ meV}) \ln \left[ \frac{0.49}{0.98} \right]$$

$$\approx -13 \text{ meV}$$

and, 
$$p_0 = \frac{(1.5 \times 10^{10})^2}{9.04 \times 10^{19}} = 2.49 / cm^3$$

[KT = 25 meV al 300 k]